JAPANESE PATENT OFFICE - Patent Abstracts of Japan

Publication Number: 05051205 A

Date of Publication: 1993.03.02

Int.Class: C01B 31/04

Date of Filing: 1991.08.23

Applicant KAWASAKI STEEL CORP Inventor: HASEGAWA KAZUHIRO SATO MASARU NAKAI SUSUMU METHOD FOR CONTROLLING GRAPHITI-ZATION DEGREE OF CARBON MATERIAL SURFACE LAYER AND METHOD FOR COATING MATERIAL SURFACE

Abstract

PURPOSE: To improve the oxidation resistance of a carbon material and to prevent a film from being peeled off by a rapid heat cycle load by irradiating the surface of the carbon material with a high-energy beam, then converting the surface to slicon carbide by a diffusion reaction and further forming a silicon carbide film by chemical vapor deposition.

CONSTITUTION: The surface of a carbon material is irradiated in an atmosphere with the oxygen partial pressure controlled to 0.1-100Torr by a high-energy beam (e.g. a laser beam having ≥lkw and/or a plasma flame with the distance between the material and a plasma gun adjusted to ≤200mm), then the surface of the material is converted to silicon carbide by diffusion reaction (e.g. the material is embedded in a ceramic powder contg. metallic silicon and allowed to react with the silicon for 30-300min), and further a silicon carbide film is formed by chemical vapor deposition (e.g. a gaseous mixture of carbon tetrachloride, methane, hydrogen and argon is subjected to reaction). Thus, the oxidation resistance of the carbon material is improved, and the film is not peeled off by a rapid heat cycle load.

COPYRIGHT: (C)1993,JPO & Japio